Original Paper

Coadsorption behavior of (CH₃)₂S with H₂O or D₂O on Rh(100) studied by XPS and NEXAFS

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(Received: November 28, 2007; Accepted: January 21, 2008)

The coadsorption reaction of $(CH_3)_2S$ with H_2O or D_2O on Rh(100) surface has been studied by XPS and S K-edge NEXAFS techniques. The $(CH_3)_2S$ gradually dissociate into methanethiolate: CH_3S -, as the temperature of the sample is elevated. S K-edge NEXAFS results indicate that the H/D exchange between $(CH_3)_2S$ and D_2O yields the angular change in the S-C bond to more flat-lying, when D_2O is introduced into this coadsorption system.

Keywords: Coadsorption Reaction; (CH₃)₂S; H₂O; D₂O; XPS; S K-edge NEXAFS.

1. Introduction

Platinum group metal catalysts are widely applied to some purification reaction of exhaust gases, particularly in the field of automobile exhaust cleaning. "Sulfur Poisoning" is an important factor in the deactivation of these catalysts. Many studies have paid attention to such problems [1-4, 5, 6]. These studies mainly investigate the interaction between the sulfur-containing molecules and the metal surfaces. We also have studied the adsorption system of (CH₃)₂S [dimethyl sulfide: DMS] on clean Rh surface, where the temperature dependent dissociation and desorption reactions have been revealed [7, 8]. These results conclude that sulfur poisoning is essentially due to the adsorption of the atomic sulfur, which blocks the contact of the exhaust gas and the catalyst surface. Therefore, the dissociative reaction of a sulfur-containing molecule is of great interest.

Actually the catalyst in practical use is set under the environment of H_2O -rich. Thus, the coadsorption reaction between sulfur-containing molecules and H_2O will give us the more actual knowledge of sulfur-poisoning. T. We have studied the coadsorption system of $(CH_3)_2S$ and H_2O on Rh(100) [9]. The S-C cleavage occurs more easily in the coadsorption with H_2O than on clean or oxygen

pre-covered surface during heating process. The paper shows that the coadsorbed species, such as H_2O and O, seriously affect the dissociation of S-C bonds.

Hydrogen isotopes (H and D) have some different properties in the chemical reactions of molecules each other. The exchange between H and D yields the change in the bond energy and the bond length. The rate of the reaction related with that bond undergoes a change (first-order isotope effect) [10]. For example, the bond energy of O-D becomes higher than that of O-H in the water isotopomeres. This induces the difference in the rate of O-H scission; the dissociation constant of H₂O is six times as large as that of D₂O. These isotopic differences are reported to influence the adsorption/desorption behavior on/from transition metal surfaces [11]. Therefore, some isotope effects are expected in such a coadsorption system with water isotopomeres.

The aim of this work is to reveal the coadsorption reaction and the isotope effect of $(CH_3)_2S$: DMS with water isotopomeres, such as H_2O or D_2O , on Rh(100) surface by means of X-ray photoelectron spectroscopy (XPS) and sulfur K-edge near edge X-ray absorption fine structure (NEXAFS) techniques.

2. EXPERIMENTAL

A commercially available Rh(100) single crystal (10 mm^{ϕ} diameter, 3 mm thickness and 99.9 % purity) was mechanically polished using 0.05 µm Al₂O₃ to a mirror finish. The Rh(100) crystal was cleaned by the alternating cycles of Ar^+ ion sputtering (3 keV, 2µA, 300 K, 30 min) to remove sulfur, carbon and oxygen impurities and annealing up to 1200 K by an electron bombardment in an ultrahigh vacuum (UHV) chamber, operating with a base pressure below 2×10⁻⁸ Pa. The cleanliness of Rh(100) surface was verified by XPS measurements (S 2p, C 1s and O 1s). The research grade DMS was purified by means of a few cycles of freezing with liquid N₂ under high vacuum condition and melting at ambient temperature. The ordered Rh(100) surface was promoted by the flash annealing up to 1200 K after 3 keV Ar⁺ sputtering for 30 min. H₂O, D₂O and DMS were admitted via the variable leak valve into the UHV chamber in this procedure, as the Rh(100) substrate was cooled down to 90 K with liquid N2. The dosages were 0.2 L for H₂O or D₂O and 0.3 L for DMS, respectively The temperature of substrate (90 ~ 200 K) was controlled by resistive heating with the W-filament, which was set behind the crystal.

S 2p, C 1s and O 1s XPS were recorded by use of AlKa X-ray (1486.6 eV) and a concentric hemispherical electron energy analyzer (ULVAC-PHI OMNI-V). The binding energy was calibrated on the assumption that the peak position of Rh 3d_{5/2} appear at 307.2 eV. The coverage of sulfur adsorbed on Rh(100) was estimated by comparison with the integral intensity of sulfur saturated phase, which corresponds to 0.5 monolayer (ML) of sulfur on Rh(100) [12-14]. Polarization dependent S K-edge NEXAFS measurements were carried out at the soft X-ray double crystal monochromator beamline BL-3 on Hiroshima Synchrotron Radiation Center (HSRC) [15, 16]. The photon energy was calibrated on the assumption that the first peak of K₂SO₄ appear at 2481.70 eV. The S-K fluorescence yield detection was employed using an UHV-compatible gasflow type proportional counter with P-10 gas which means the mixed gas of 10 % CH_4 and 90 % Ar.

3. RESULTS AND DISCUSSIONS

3.1. XPS results

Fig. 1 shows the temperature dependent S 2p XPS



Fig. 1. Thermal dependent S 2p XPS spectra for the coadsorption system of DMS with H_2O or D_2O on Rh(100).

spectra for the coadsorption of DMS with water isotopomeres (H₂O and D₂O) on Rh(100) surface. The estimated sulfur coverages for each sample are shown in Fig. 1. These amounts are small enough for ruling out the second layer. At 90 K, the spectra for DMS with each water isotopomeres can be deconvoluted into two chemical states, where the solid lines are superimposed on the S $2p_{3/2}$ position. These peaks are assigned to DMS and methanethiolate (CH₃S-: MT) [5]. MT is formed by the cleavage of the S-C bonds in DMS molecule. Thus, DMS molecules partially dissociate at 90 K. The sulfur included in MT is seemed to directly bond to the substrate at 90 K, because the peak position of MT (163.2 eV) is corresponding to that on clean Rh(100) surface [5]. When the samples are heated up to 200 K, the peak intensities of DMS and MT drastically decrease on both surfaces. Another peak appears additionally at around 162 eV, which

Journal of Surface Analysis Vol.14, No. 4 (2008) pp. 453-457

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Fig. 2. Thermal dependent C 1s XPS spectra for the coadsorption system of DMS with H_2O or D_2O on Rh(100).

represents the formation of atomic sulfur chemisorbed on Rh(100) [7]. Most of the S-C bonds in DMS and MT are broken at 200 K, because quite a small amount of DMS and MT remains on Rh(100) surface. There is also the desorption of adsorbates from the surface. According to the previous study [8], the main desorbed species seem to be the chemisorbed DMS molecules, and most of MT decomposed into atomic sulfur.

The C 1s XPS spectra of the same samples are also shown in Fig. 2, where these spectra have already been subtracted the suitable background spectrum measured before DMS adsorption. Two peaks are found in these spectra. The first peak at 284.2 eV is assigned to CHx (x = 2 or 3) species chemisorbed on Rh(100), which is formed by the scission of S-C bonds [17]. The second peak presents the methyl bonding to sulfur atom, such as DMS and MT. There has already been the peak for CHx at 90 K, which indicates the decomposition of DMS molecules. That peak intensity is enhanced as the temperature rises, and simultaneously the decrease of the



Fig. 3. Sulfur K-edge NEXAFS spectra for the coadsorption system of DMS with H_2O or D_2O on Rh(100) at 90 K.

peak intensity for MT and DMS occurs. Therefore, we can observe the thermal dissociation of DMS and MT in the C 1s XPS spectra. When the sample is heated up to 200 K, the C 1s XPS spectrum becomes having a single peak of CHx species. Thus, most of the S-C bonds have already been cleaved. The results of S 2p and C 1s XPS are corresponding to each other. One cannot obtain any isotopic differences in the thermal reaction between DMS and water isotopomeres.

3.2. S K-edge NEXAFS results

Fig. 3 shows the S K-edge NEXAFS spectra for the coadsorption of DMS with water isotopomeres on Rh(100) surface at 90 K. The glancing angle θ is also the polar angle of electric field vector of the incident X-rays with respect to the surface normal. One can obtain the tilt angle of the chemical bond by means of the dipole selection rule between electric field vector and the transition moment. These spectra are normalized by the edge-jump with each other. We can find a peak at 90° and a shoulder

structure at 20° in the spectra. The main peak at 2474.0 eV is assigned to the transition on S 1s $\rightarrow \sigma^*(S-C)$ of DMS. The shoulder structure at 2472.5 eV is ascribed to that on S 1s $\rightarrow \sigma^*(S-C)$ of MT [7]. The polarization dependence for the intensity of the $\sigma^*(S-C)$ indicates that the tilt angle of S-C bond in DMS is almost lying flat on Rh(100) surface, because the maximum of the peak intensity occurs at $\theta = 90^{\circ}$. On the other hand, the S-C bond of MT is located to be perpendicular to the surface qualitatively. These tendencies for the S-C orientations are similar between H₂O and D₂O as the coadsorbates. However, a little difference depending upon the water isotopomeres can be seen in the peak intensities. For normal X-ray incidence ($\theta = 90^\circ$), the peak of DMS is enhanced more on the coadsorption with D₂O than H₂O. On the other hand, the peak height for DMS and MT is intensified with H₂O at grazing X-ray incidence ($\theta = 20^{\circ}$). These tendencies represent that the coordination angle of the S-C bonds becomes more flat-lying in regard to Rh(100) surface, when D₂O is introduced to this coadsorption system. This structural change in the tilt angle of the S-C bond is attributed to the H/D exchange reaction in the methyl group. The H/D exchange between D₂O and other molecules, as in H₂O and an amide group, have reported [18, 19]. The displacement into deuterium leads to shorten the bond length between a certain atom and hydrogen because of the vibrational change [20]. In this study, some of the C-H bonds are speculated to be replaced into the C-D bonds. These methyl groups can come to approach more to the Rh(100) surface, because the S-C bond axes of DMS molecule is almost lying flat on the surface [7]. Simultaneously, the coordination angle of the S-C bond makes closer to parallel to the surface qualitatively.

4. CONCLUSION

We have investigated the coadsorption behavior of DMS with H_2O or D_2O on Rh(100) surface by XPS and S K-edge NEXAFS techniques. A part of DMS molecules coadsorbed with H_2O or D_2O dissociates into MT on Rh(100) surface at 90 K. DMS and MT gradually decompose into atomic sulfur, when the samples are annealed. Most of the S-C bonds undergo a scission at 200 K. There is little difference between H_2O and D_2O in the coadsorption reaction. On the other hand, S K-edge NEXAFS study shows that the tilt angle of the S-C bond

change into more flat-lying, when D_2O is admitted into this coadsorption system. The change in the adsorption structure is supposed to be caused by the H/D exchange between DMS and D_2O .

5. Acknowledgements

The authors are grateful for the financial supported of a Grant-in-Aid for Scientific Research from the Ministry of Education, Science and Culture, Japan (No. 19008872 and 15360358), 21-Century COE "Isotope Science and Engineering from Basics to Applications" and Innovation Hiroshima/Tokai of JST (Japan Science and Technology Agency). This work was performed under the approval of HSRC Program Advisory Committee (Nos. 06-A-20 and 06-A-21).

6. References

- [1] S. Yagi, A. Matano, G. Kutluk, N. Shirota, E. Hashimoto, M. Taniguchi, *Surf. Sci.* 482, 73 (2001).
- [2] S. Yagi, Y. Nakano, E. Ikenaga, S. A. Sardar, J. A. Syed, K. Soda, E. Hashimoto, K. Tanaka, M. Taniguchi, *J. Vac. Sci. Technol.* A 20, 1644 (2002).
- [3] Z. Paál, K. Matusek, M. Muhler, *Appl. Catal. A: General* 149, 113 (1997).
- [4] H. Wakita, Y. Kani, K. Ukai, T. Tomizawa, T. Takeguchi, W. Ueda, *Appl. Catal. A: General* 283, 53 (1997).
- [5] H. S. Gandhi, M. Shelef, Appl. Catal. 77, 175 (1991).
- [6] A. K. Neyestanaki, F. Klingstedt, T. Salmi, D. Y. Murzin, *Fuel* 83, 395 (2004).
- [7] T. Nomoto, S. Yagi, G. Kutluk, K. Soda, E. Hashimoto, M. Taniguchi, *J. Surf. Anal.* **12**, 238 (2005).
- [8] T. Nomoto, S. Yagi, K. Soda, G. Kutluk, H. Sumida, E. Hashimoto, M. Taniguchi, *e-J. Surf. Sci. Nanotech.* 4, 39 (2006).
- [9] T. Nomoto, O. Sumi, S. Yagi, K. Soda, H. Namatame and M. Taniguchi, *Surf. Interface Anal.* in press.
- [10] E. Vedejs, J. Little, J. Am. Chem. Soc. 124, 749 (2002).
- [11] D.N. Denzler, S. Wagner, M. Wolf, G. Ertl, *Surf. Sci.* 532, 113(2007).
- [12] W. Liu, J. R. Lou, K. A. R. Mitchell, Surf. Sci. 281, 21 (1993).
- [13] V. R. Dhanak, S. P. Harte, G. Scarel, B. C. C. Cowie, A. Santoni, *Surf. Sci.* 366, L765 (1996).

- [14] J. R. Mercer, G. Scarel, A. Santoni, B. C. C. Cowie, D. Lewis, A. W. Robinson, R. McGrath, V. R. Dhanak, *Surf. Sci.* 369, 36 (1996).
- [15] M. Taniguchi, J. Ghijsen, J. Synchrotron Radiat. 5, 1176 (1998).
- [16] S. Yagi, G. Kutluk, T. Matsui, A. Matano, A. Hiraya,
 E. Hashimoto, M. Taniguchi, *Nucl. Instr. and Meth.* A 467, 723 (2001).
- [17] L. Colin, A. Cassuto, J.J. Ehrhardt, M.F. Ruiz-Lopez,

D. Jamois, Appl. Surf. Sci. 99, 245 (1996).

- [18] T. F. Roland, J. Borysow, M. Fink, J. Nucl. Mater. 353, 193 (2006).
- [19] M. Hoshino, H. Katou, K. Yamaguchi, Y. Goto, *Biochimica et Biophysica Acta* 1768, 1886 (2007).
- [20] R. Kato, H. Sawa, S. Aonuma, M. Tamura, M. Kinoshita, H. Kobayashi, *Solid State Commun.* 85, 831 (1993).